

OS2 (Room B)

DAY1

Wednesday 7th December

Oral Session (OS2-5 - OS2-8) Microstructure - I Chair: Yoshimasa TAKAHASHI (Kansai University)	
15:30 - 16:50	OS2-5 (C10058) Reaction-Diffusion Theory for Self-Organized Dislocation Patterning in Fatigued Metals ○Hiroyuki SHIMA (University of Yamanashi), Akihiro TOBISE, Yuri AKIBA, Yoshitaka UMENO, Takashi SUMIGAWA
	OS2-6 (C10123) Swirl Cast/WEDM Examination of Al-7075/SiC&Al ₂ O ₃ ○Angadi SESHAPPA (Vardhaman College of Engineering), Prasad B ANJANEYA
	OS2-7 (C10144) The Effect of Cu Addition on the Tensile and Fatigue Behavior of NiTi Shape Memory Alloy Thin Films ○Hyemin RYU (Korea Advanced Institute of Science and Technology), Zhuo Feng LEE, Abdul REHMAN, Ji-Young KIM, Sunkun CHOI, Gi-Dong SIM
	OS2-8 (C10064) An Optimum Twin Thickness of Strength in Face-Centered Cubic Metals through Molecular Dynamics Simulation Islam Mohammad RAZZAKUL (Kanazawa University), Tomoaki NIIYAMA, ○ Tomotsugu SHIMOKAWA